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A feasible strategy to prepare quantum dot-incorporated carbon nanofibers as free-standing platforms†

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Recently, quantum dots (QDs) have often garnered significant attention and have been employed for various applications. Nevertheless, most conventional devices utilize a glass substrate and/or brittle substrate, which is not compatible with next-generation wearable electronics. A suitable method for devising conductive and flexible free-standing platforms that can be combined with various kinds of QDs is thus in great need for next-generation wearable electronics. In this work, we introduce a universal and simple method to coat QDs on carbon nanofibers (CNFs) by a dip-coating process, where many kinds of QDs can be well decorated on the surface of CNFs. As one potential application among many, QD-coated CNFs were examined for their photocatalytic applications and characterization. As a result, it was found that the best performance of CdSe QD-coated CNFs for hydrogen production was 3.8 times higher than that of only QDs with the same 1 mg of QDs. This is an early report on fabricating various kinds of QD-coated CNFs, which can be extended to a myriad set of applications.

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Introduction

Quantum dots (QDs) have received considerable attention, not only in the fields of photovoltaic solar cells¹ but also in the fields of light emitting diodes,² neuroscience,³ batteries,⁴ and photo-detectors.^{5,6} The popularity of QDs can be attributed to their quantum confinement effect based on confinement in three spatial dimensions by the potential barrier,⁷ as well as the fact that QDs offer the advantages of simple processing, large-scale production, and facile control of energy levels of the junction with the substrate using changeable highest occupied molecular orbital (HOMO) and lowest unoccupied molecular orbital (LUMO) levels of QDs.^{1,5} Much research has already been conducted for using QDs as crucial components of optoelectronics, some of which include, but are not limited to, PbS–MoS₂,⁵ PbS,⁶ ZnO,⁸ HgTe,⁹ and Ge.¹⁰

With the emergence of the IoT technology, wearable/flexible electronics have received tremendous attention.^{11,12} For such technology, it is critical to use a conductive free-standing platform. *In lieu* of these trends, a majority of devised optoelectronics have been based on brittle substrates,^{4–6,9,10} although some literature has been reported on wearable/flexible substrates.⁸ A facile strategy to make a QD-conductive free-standing substrate needs to be devised to establish a milestone for next-generation electronic devices.

Among the materials for free-standing substrates, carbon nanofibers (CNFs), simply prepared using electrospinning, have the advantage of being low cost and have been highlighted. CNFs have been studied as a structure coated with various materials such as Co₄N, WS₂, CdS, ZnO, AgS₂, TiO₂, and ZnIn₂S₄ and so on. Most of these coated structures have been formed by allowing materials to grow and crystallize on the surface of CNFs using various methods.^{13–20} The methods include the solvothermal method, the hydrothermal method, successive ionic layer adsorption and reaction, and heat treatment under specific gas-flowing conditions.^{13–18,21,22} However, these methods have disadvantages in that they involve a difficult synthesis process, result in problematic surface uniformity, and are not amenable to mass production. The mechanical and physical properties of CNFs also change due to the additional chemical reaction.

In this work, we firstly suggest a highly facile CNF platform coated with various QDs using a simple dip-coating process. The dip-coating is universal and scalable, and it can be used for

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Scanning electron microscopy (SEM) images of pristine CNFs and various QD-coated CNFs are presented in Fig. 2. Prior to coating QDs onto CNFs, the intrinsic properties, such as the absorbance and photoluminescence (PL) spectra, of ten different kinds of QDs (CdSe, PbS, InP, CuInS₂, CdS, InP/ZnS, CuInS₂/ZnS, CdSe/ZnS, CdZnSeS/ZnS, and CdZnS/ZnS) were recorded and confirmed (Fig. S1†). The low and high magnification SEM images of pristine CNFs with a fiber thickness of about 300–500 nm are shown in Fig. 2a and b, respectively. The ten different kinds of QDs dispersed in hexane with identical concentration (20 mg mL⁻¹) were easily coated onto CNFs by simple dip-coating for 1 min (Fig. 2c–l), although some were difficult to detect. Such a discrepancy is dependent on the particle size of individual QDs – when the size of QDs is around 10 nm, they are visible in the SEM image, but the sizes less than 5 nm become difficult to detect. Based on Fig. 2c–l, it is apparent that various kinds of QDs are homogeneously coated onto the CNF surface by dip-coating. In addition, low magnification SEM images (Fig. S2†) confirm that the nanofibrous structure was well maintained after the dip-coating process, in which coating of the QDs did not alter the overall morphology. For the detailed study of electrical junction properties between the QDs and the CNFs, we chose a CdSe QD-coated CNF (denoted as CdSe–CNF) among the aforementioned QDs. To further delve into the concentration effect of QDs on the overall

As the size of the QDs is generally less than 10 nm, transmission electron microscopy (TEM) analysis was used to investigate the exact microstructure of CdSe–CNF 20 (Fig. 3). The high-resolution TEM (HRTEM) images and the corresponding selected area diffraction (SAED) pattern of CdSe QDs are shown in Fig. 3a, b, and e, revealing the successful synthesis of QDs. The low and high magnification TEM images of CdSe–CNF further confirm the uniform deposition of QDs, in which a number of QDs are deposited on the surface of the CNFs (Fig. 3c and d). The CdSe–CNF SAED patterns have also shown that the crystal structures of QDs coated on the CNFs are similar to those of QDs only (Fig. 3e). To investigate the overall

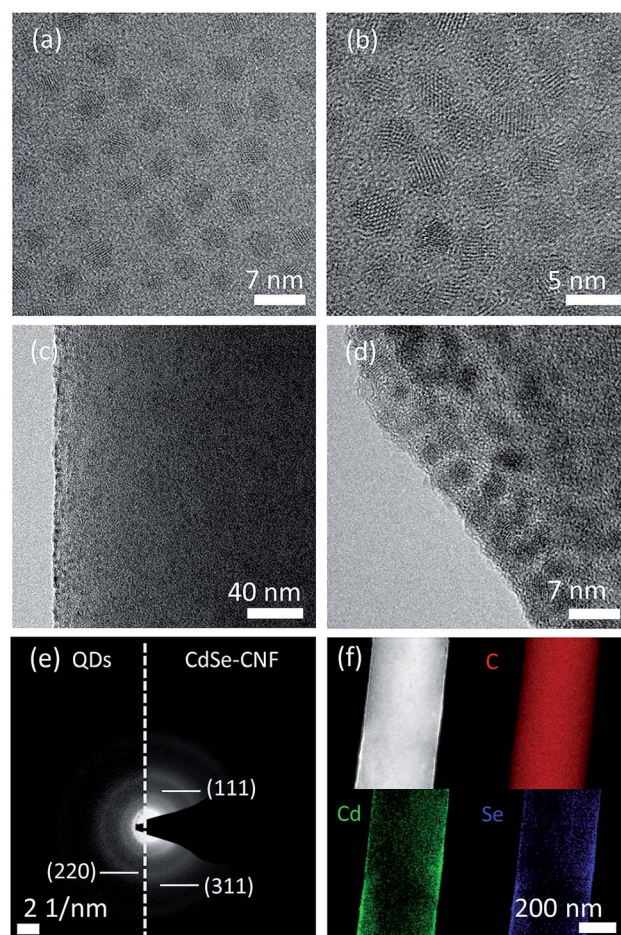


Fig. 3 (a) TEM image and (b) HRTEM image of CdSe QDs. (c) TEM image and (d) HRTEM image of CdSe–CNF 20. (e) SAED patterns of (left) CdSe QDs and (right) CdSe–CNF 20. (f) TEM-EDS mapping of CdSe–CNF 20.

We also conducted quantitative and structural analyses regarding the coating concentrations of CdSe QDs. Based on the inductively coupled plasma mass spectrometry (ICP) analysis of CdSe–CNF (Table S2†) and the trend in the average amount of CdSe QDs with respect to the weight of CdSe–CNF (Fig. 4a), it is clear that both the atomic and weight ratios of Cd and Se increase with respect to C with the increase of the coating concentration. Based on the X-ray diffraction (XRD) patterns, when the coating concentration of CdSe QDs increases, the intensities of crystalline peaks for CdSe (ICDD no. 01-073-6987) also proportionally increase (Fig. 4b). CdSe–CNF 100 exhibits the most pronounced crystalline peaks, followed by CdSe–CNF 50 and CdSe–CNF 20. The presence of other QDs (such as InP and CuInS₂) on the CNFs is also clearly confirmed by the XRD patterns at a coating concentration of 20 mg mL^{−1} (Fig. S7†). Furthermore, Fig. 4c shows that the coated QD layer becomes thicker with the increase of the coating loaded amount of CdSe QDs. This can be inferred from the elemental intensity of TEM-EDS mapping at the edge site of the CdSe–CNFs. As mentioned previously, from the point of view of the 2D EDS mapping images, the CdSe QDs are densely located at the edge site due to the cylinder shape of the CNFs. The intensity of the Cd element is higher at the edge site than at the inner site, and Fig. 4c shows

The absorbance and PL spectra of CdSe QDs dispersed in hexane are shown in Fig. 5a. The PL peak of the synthesized CdSe QDs is at 582.8 nm. In addition, Fig. 5a shows the PL spectra of the CdSe–CNFs and a CdSe QD layer on glass. The PL intensity and PL peak of the CdSe QD layer on glass were lower and shifted to a longer wavelength, respectively, when compared with those of CdSe QDs dispersed in hexane. In the latter case, the distance between QDs is relatively shorter than the distance between QDs dispersed in hexane solution. As the distance becomes shorter, non-radiative Förster resonance energy transfer (FRET) becomes more activated between QDs, and the PL peak shifts from 583.2 nm to 591.1 nm. The FRET enables excited electron–hole pairs in QDs not to emit light but to excite the other QDs in close proximity, and generates a red-

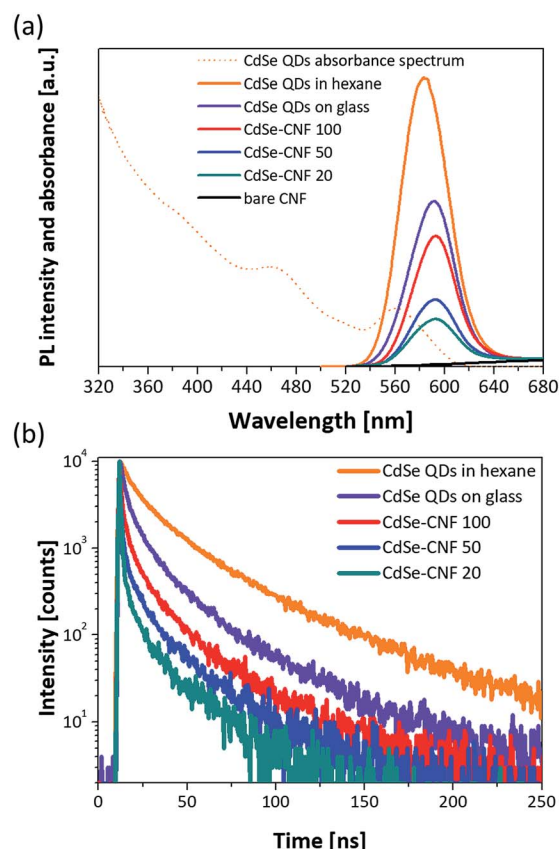


Fig. 5 (a) Absorbance and PL spectra of the synthesized CdSe QDs dispersed in hexane and PL spectra of CdSe–CNFs and a CdSe QD layer on glass. (b) Transient PL decay curves of CdSe QDs in hexane, a CdSe QD layer on glass, and CdSe–CNFs. Every characterization is performed using a source of light (excitation wavelength = 470 nm). For the CdSe QD film on glass, the CdSe QDs (20 mg mL⁻¹ in hexane) were spin coated on glass at 2000 rpm for 30 s.

The values in Table 1 were fitted with a biexponential function composed of fast (τ_1) and slow (τ_2) decay components assigned to a radiative and a non-radiative recombination process, respectively. The fast decay component of CdSe QD solution shifts from 10.00 ns to 0.97 ns for CdSe–CNF 20, and its proportion increases from 41.64% to 58.53%. The fast decay component, which is assigned to non-radiative recombination, means that the PL of CdSe QDs is quenched by the junctions.^{32,42} In addition, with decreasing proportion of the slow decay time component assigned to the radiative process, the PL intensity was reduced. While CdSe–CNF 20 has the shortest decay time (7.34 ns), CdSe–CNF 100 has a longer decay time of 12.15 ns. When the coating concentration is increased, the amount of coated CdSe QDs increases, and the CdSe QD layer on the CNF obviously becomes thicker. Then, the ratio of

	In hexane	On glass	CdSe-CNF 100	CdSe-CNF 50	CdSe-CNF 20
τ_1 [ns]	10.00	4.89	2.29	1.19	0.97
f_1 [%]	41.64	49.81	44.34	44.51	58.53
τ_2 [ns]	44.15	28.30	20.00	16.91	16.32
f_2 [%]	58.36	50.19	55.66	55.49	41.47
τ_{avg} [ns] ^a	29.93	16.64	12.15	9.91	7.34

Nanoscale Adv., 2019, 1, 3948–3956 | 3953

Additionally, photosensitivity was measured using the free-standing structure of CdSe-CNF 20, and it was significantly enhanced, with the augmentation of photo-current (I_{ph}) with respect to dark-current (I_{dark}) being almost 1.7 times greater

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